## The MuPix8 Chip A monolithic large scale pixel sensor

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- $\mu^+ \to e^+ e^- e^+$ ( $\nu$ SM: BR < 10<sup>-54</sup>)
- current limit (SINDRUM)
  BR < 10<sup>-12</sup> @ 90% CL
- aiming for sensitivity of 1 in 10<sup>16</sup> decays



R.M.Djilkibaev and R.V.Konoplich,

Phys.Rev., D79 073004, 2009

- muons decay at rest:  $\Sigma \vec{p} = 0$
- common vertex and coincident in time
- reconstruct invariant mass
  (E<sub>tot</sub> = m<sub>µ</sub>)
- max momentum 53 MeV





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#### The Mu3e Experiment



- 10<sup>9</sup> muon decays per second
- good vertex & time resolution (100 µm & 500 ps)
- good momentum resolution (0.5 MeV)

#### The Mu3e Experiment



Multiple Coulomb Scattering:  $\Theta \propto \frac{1}{p} \sqrt{x/X_0}$ 

- optimize the material budget
- thin silicon sensors required  $1\% X_0$
- → HV-MAPS

## High Voltage - Monolithic Active Pixel Sensor (HV-MAPS)



I.Peric, P. Fischer et al., NIM A 582 (2007) 87

- low ohmic substrate  $(20 \,\Omega \,\text{cm})$
- high voltage (100 V)
- AMS 180nm HV-CMOS

- depleted n-well diode
- charge collection via drift
- no additional readout chip

#### MuPix7 - Summary



- $80 \times 103 \, \mu m^2$  pixel size
- $3.3 \times 3.3 \, \text{mm}^2$
- full system on-chip
- 1.25 Gbit s<sup>-1</sup> data rate
- 99.5% efficiency with 14.3 ns time resolution
   0 300 mW cm<sup>-2</sup>

#### MuPix8 Design Features

- $80 \times 80 \,\mu\text{m}^2$  pixel size
- $\blacksquare~2\times1\,\text{cm}^2$  active area
- module building
- improve time resolution
- radiation hard design
- increase active volume (80 Ω cm substrate)



#### MuPix8 Design Features

- $80 \times 80 \,\mu\text{m}^2$  pixel size
- $2 \times 1 \, \text{cm}^2$  active area
- module building
- improve time resolution
- radiation hard design
- increase active volume (80 Ω cm substrate)

~10.8 mm ~21.6 mm MuPix8 19.5 mm Periphery

# MuPix8 Chip



- $81 \times 80 \, \mu m^2$  pixel size
- $17 \times 10 \text{ mm}^2$  active area
- 128 × 200 pixels
- 3 matrix partitions

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## MuPix8 Electronics



- timewalk reduction circuitry
- 3 sub-matrices with dedicated data output
- additional merged data output



- very dense routing:
  2 metal layers, 200 signals
  - 300 nm spacing
- 1 sub-matrix source follower
- 2 sub-matrices current driven

## Peripheral Cell



- 3 time walk correction approaches
- 2 comparators
- 10(+6) timestamp bits
- 3 Tune bits + pixel switch

#### Timewalk Correction - Two Thresholds



simple

timewalk suppression on-chip

#### Timewalk Correction - Two Thresholds



- ToT sampling
- improve measurement with ramp
- off-chip timewalk correction necessary

## Conclusion



- first large monolithic prototype
- expected in April
- module suitable
- exciting characterisation times ahead